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ATTY. DOCKET NO. APV31897

To be assigned

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

26 SEP 2005

(Use several sheets if necessary)

Entered US National Phase September 26, 2005

GROUP

U.S. PATENT DOCUMENTS

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FOREIGN PATENT DOCUMENTS

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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

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EXAMIN	ER	/Edna Wong/	DATE CONSIDERED	11/10/2008					

EXAMINER: Initial if citation is considered, draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.